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Assistant Connissioner for Patents

Washington D.C. 20231

Atty Docket No.: 0630.0021C

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the PATENT application of:

Berry et al

Examiner: Le, Thao X.

Serial No.: 09/505,695

Group Art Unit: 2814

Filed: February 17, 2000

Method of Photoresist Ash Residue Removal

## TRANSMITTAL LETTER

COMMISSIONER FOR PATENTS Washington, D.C. 20231

Sir:

Transmitted herewith for filing in the above-identified application is an Amendment (8 pages), Petition for Extension of Time and Check No. 6246 in the amount of \$110.00 for payment of the extension of time fee

Respectfully submitted,

Martin Abramson

Registration No. 25,787

Epstein, Edell, Shapiro, Finnan & Lytle, LLC 1901 Research Blvd., Suite 400 Rockville, Maryland 20850-3164 (301) 424-3640



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For:

Method of Photoresist Ash Residue Removal

**AMENDMENT** 

Commissioner for Patents Washington, D.C. 20231

Sir:

Responsive to the Office Action of May 17, 2002, please amend the above-identified application as follows:

# **IN THE CLAIMS:**

Please cancel claims 1 and 12 without prejudice to their re-entry at a later date, and amend claims 2, 13 and 14 as shown below. Please add new claims 20 - 23. Please see the Appendix attached hereto for a version of the amended claims with markings to show the changes made.

2. (Amended) The method of claim 21 wherein the gas and/or vapor is comprised

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